PATENT ABSTRACTS OF JAPAN

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(54) GAS SEPARATION MEMBRANE

(57) Abstract:

PURPOSE: To obtain a gas separation membrane excellent in oxygen permeability, chemical resistance and mechanical strength, by forming the same from a polyurea/silicone copolymer having a polysiloxane structure into the main chain of the polyurea thereof.

CONSTITUTION: A gas separation membrane has a structural unit shown by a formula and, for example, prepared as mentioned hereinbelow. That is, in a solution of bis(γ-aminopropyl)tetramethyldisloxane in Nmethyl-2-pyrrolidone, a solution of diphenylmethane diisocyanate in a solvent mixture consisting of Nmethyl-2-pyrrolidone and methyl isobutyl ketone is dripped in a small increment and the resulting mixture is reacted under heating. The reaction mixture is thrown into a large amount of water to precipitate a copolymer. After a 5wt% solution of this copolymer in N-methyl-2-pyrrolidone is cast on a tin plated plate, the formed film is heated at 20°C for 4hr and further heated at 150 °C for 1hr to evaporate the solvent and a homegeneous copolymer membrane is obtained. This membrane has coefficient of O2-permeation of 3.1×10⁻¹⁰cm². cm/cm².sec cm Hg and coefficent of N_2 -permeation of 7.7×10^{-11} cm².cm/cm²sec cm Hg.

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$$R^2$$
 R^2 R^2 R^2 — SMCONII-R 1 – NHCONII (CH $_2$) $^{-Si}_{1}$ – $(OSi)_{n}$ – $(CH_2)_{n}$ – $(CH_$